

Docket No.: 50432-067

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of :  
Kai YANG, et al. :  
Serial No.: : Group Art Unit:  
Filed: March 27, 2001 : Examiner:  
For: STABILIZING FLUORINE ETCHING OF LOW-K MATERIALS

**PRELIMINARY AMENDMENT**

Commissioner for Patents  
Washington, DC 20231

Sir:

Prior to examination of the above-referenced application, please amend the application as follows:

IN THE TITLE:


Please change the title from "DAMASCENE PROCESSING USING DIELECTRIC BARRIER FILMS" to --STABILIZING FLUORINE ETCHING OF LOW-K MATERIALS--.

**REMARKS**

Entry of this preliminary amendment is respectfully requested.

Respectfully submitted,

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